## Amendment to the Specification:

On page 11, please replace the paragraph beginning at line 19 with the following amended paragraph:

Figure 6 represents a fifth step of that method[[.]],

On page 11, after line 19, please add the following paragraph:

Figure 7 illustrates the silicon plate of Figure 3, having a non-continuous sacrificial layer.

On page 16, please replace the paragraph beginning at line 26 with the following amended paragraph:

It is clear that a non-continuous sacrificial layer <u>3</u> may be obtained <u>as shown in Figure 7</u>, for example by localized deposition or by etching; this enables areas already opened up to be defined in the stacked structure.